

EEE-2103: Electronic Devices and Circuits

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Characteristics of JFETs

Applying Shockley's Equation:

Obtaining transfer curve →

$$V_{GS} = 0 \text{ V gives } I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_P}\right)^2 = I_{DSS} \left(1 - \frac{0}{V_P}\right)^2 = I_{DSS}$$

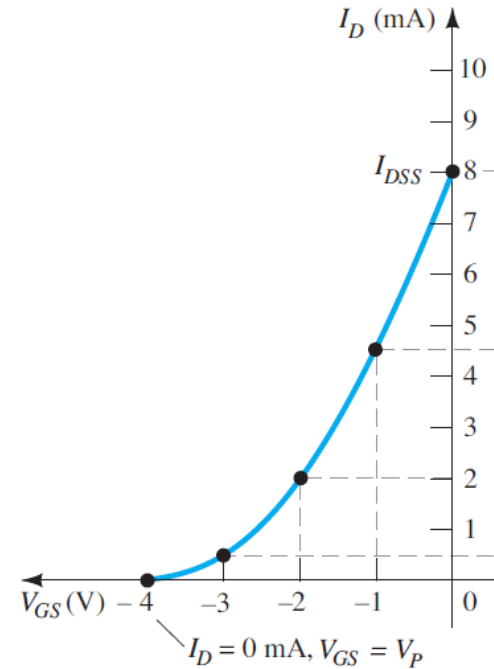
$$V_{GS} = V_P \text{ yields } I_D = I_{DSS} \left(1 - \frac{V_P}{V_P}\right)^2 = I_{DSS}(1 - 1)^2 = 0$$

$$V_{GS} = -1 \text{ V gives } I_D = I_{DSS} \left(1 - \frac{-1}{-4}\right)^2 = 8 \times 10^{-3} \left(1 - \frac{1}{4}\right)^2 = 4.5 \text{ mA}$$

Equation for resulting level of V_{GS} for given level of I_D →

$$V_{GS} = V_P \left(1 - \sqrt{\frac{I_D}{I_{DSS}}}\right)$$

$$\begin{aligned} I_D = 4.5 \text{ mA gives } V_{GS} &= V_P \left(1 - \sqrt{\frac{I_D}{I_{DSS}}}\right) = -4 \left(1 - \sqrt{\frac{4.5 \times 10^{-3}}{8 \times 10^{-3}}}\right) \\ &= -4(1 - 0.75) = -1 \text{ V} \end{aligned}$$



Characteristics of JFETs

Problem-34:

Sketch the transfer curve for an n -channel JFET defined by $I_{DSS} = 12 \text{ mA}$ and $V_P = -6 \text{ V}$.

2 plot points are

$$I_{DSS} = 12 \text{ mA and } V_{GS} = 0 \text{ V}$$

$$I_D = 0 \text{ mA and } V_{GS} = V_P = -6 \text{ V}$$

Another 2 points are

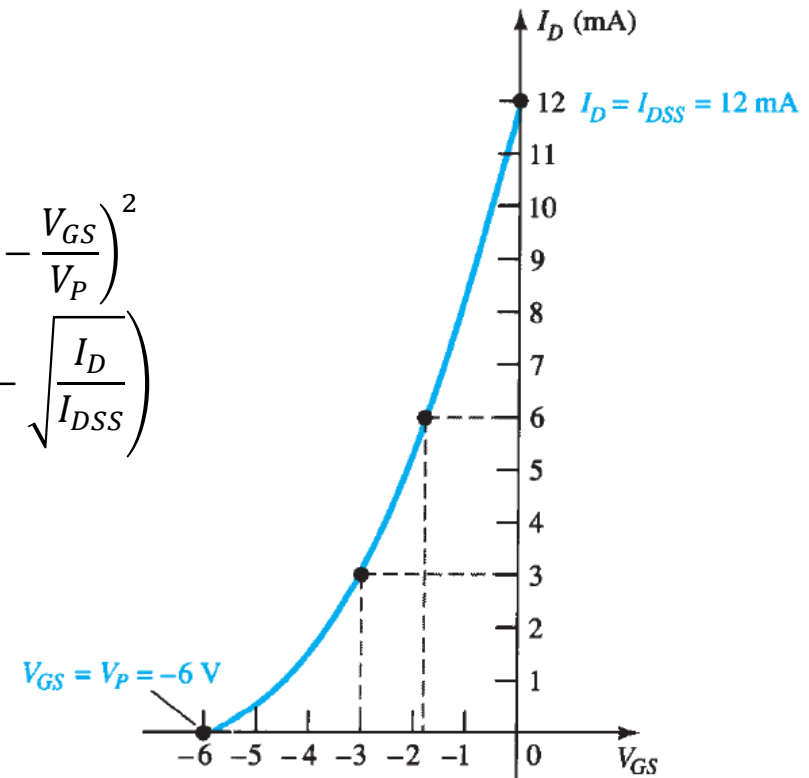
$$\text{At } V_{GS} = V_P/2 = -6/2 = -3 \text{ V}$$

$$I_D = I_{DSS}/4 = 12/4 = 3 \text{ mA.}$$

$$\text{At } I_D = I_{DSS}/2 = 12/2 = 6 \text{ mA}$$

$$V_{GS} = 0.3 V_P = 0.3(-6) = -1.8 \text{ V.}$$

$$I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_P} \right)^2$$
$$V_{GS} = V_P \left(1 - \sqrt{\frac{I_D}{I_{DSS}}} \right)$$



Characteristics of JFETs

Problem-35:

Sketch the transfer curve for a p -channel JFET with $I_{DSS} = 4 \text{ mA}$ and $V_P = 3 \text{ V}$.

2 plot points are

$$I_{DSS} = 4 \text{ mA and } V_{GS} = 0 \text{ V}$$

$$I_D = 0 \text{ mA and } V_{GS} = V_P = 3 \text{ V}$$

Another 2 points are

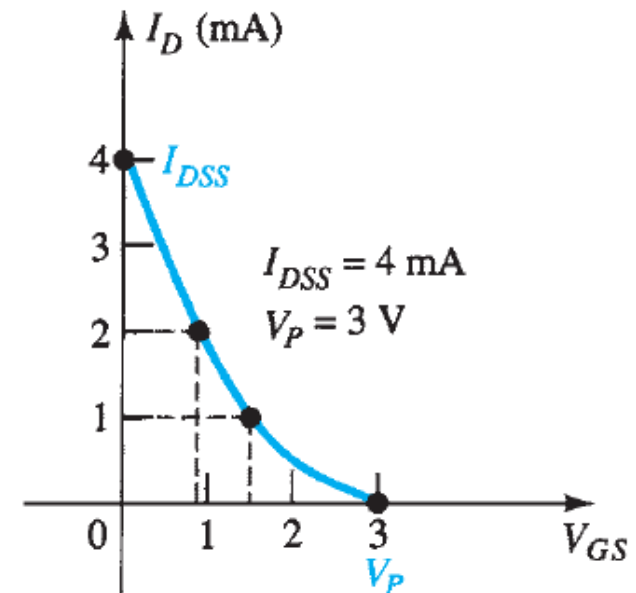
$$\text{At } V_{GS} = V_P/2 = 3/2 = 1.5 \text{ V}$$

$$I_D = I_{DSS}/4 = 4/4 = 1 \text{ mA.}$$

$$\text{At } I_D = I_{DSS}/2 = 4/2 = 2 \text{ mA}$$

$$V_{GS} = 0.3 V_P = 0.3(3) = 0.9 \text{ V.}$$

$$I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_P} \right)^2$$
$$V_{GS} = V_P \left(1 - \sqrt{\frac{I_D}{I_{DSS}}} \right)$$



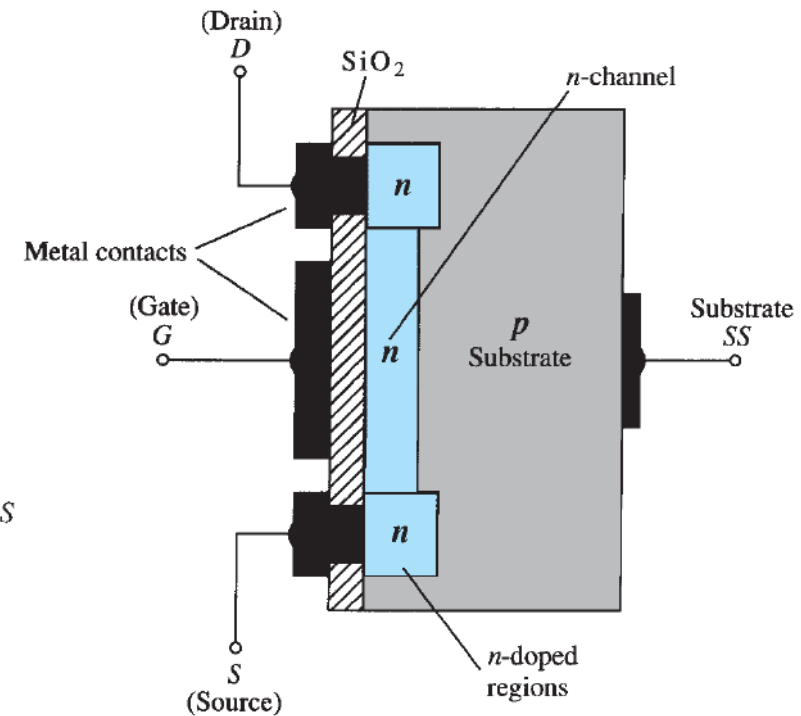
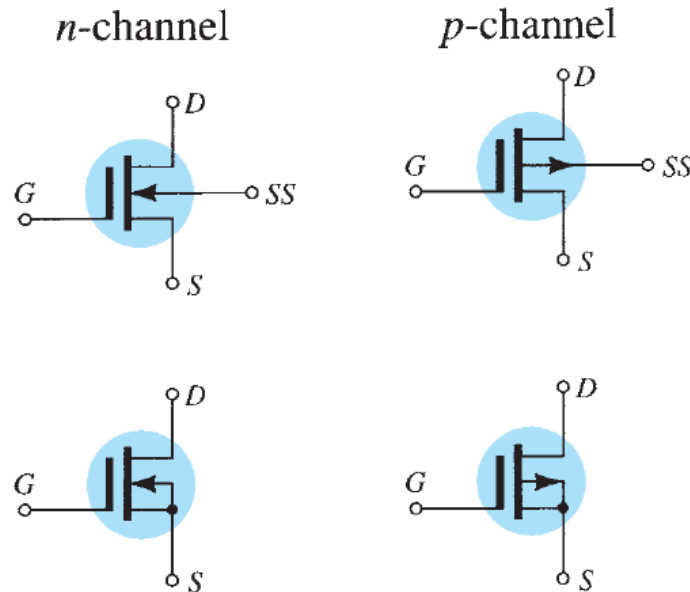
Depletion-Type MOSFET

Construction of n -channel DMOSFET:

SiO_2 insulator = dielectric.

Exposed to externally applied field \rightarrow
sets up opposing electric fields within dielectric.

Very desirable high input impedance.

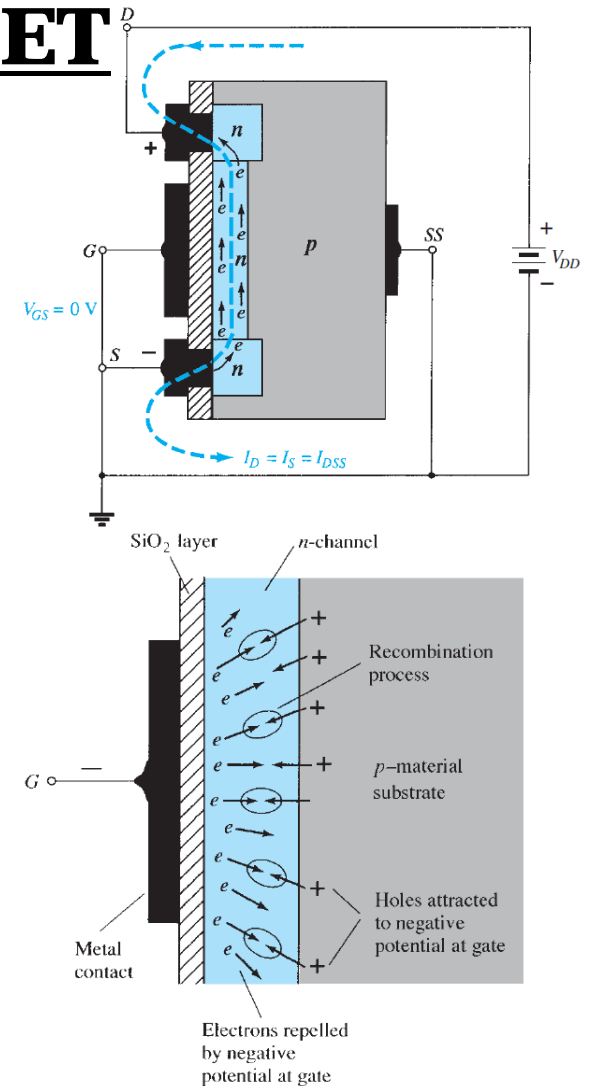
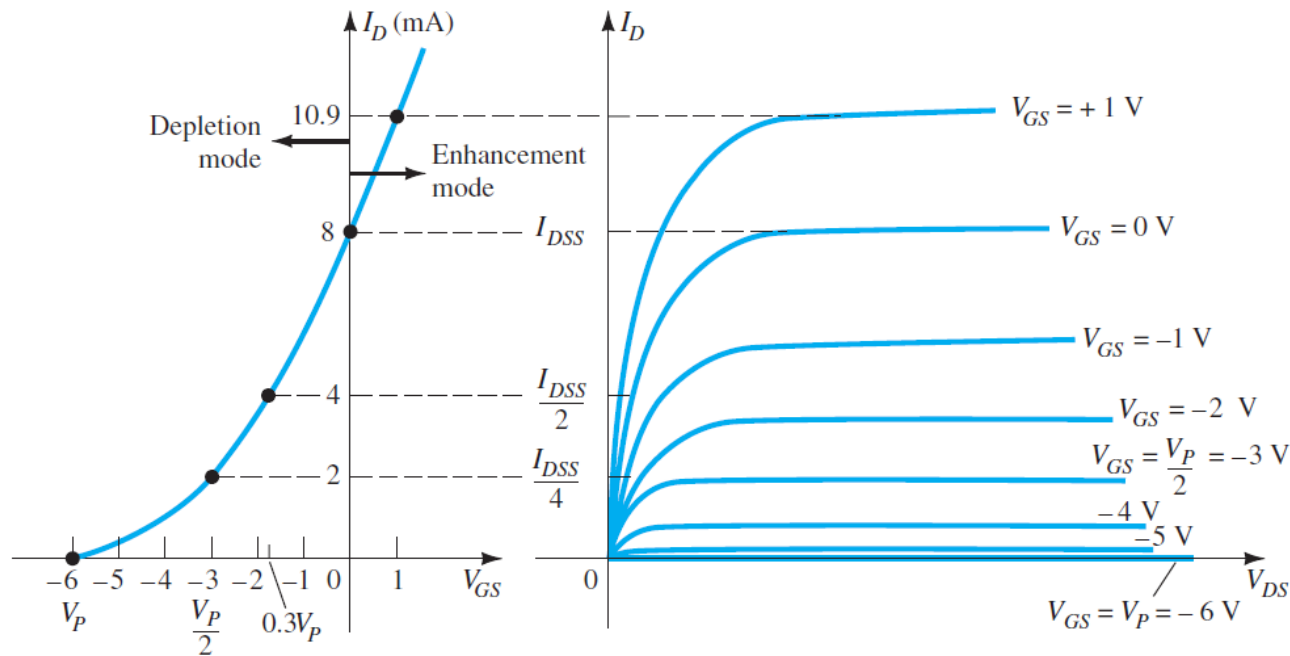


Depletion-Type MOSFET

Basic operation and characteristics:

Enhancement region → region of +ve gate voltages on drain or transfer characteristics.

Depletion region → region between cutoff and saturation level of I_{DSS} .



Depletion-Type MOSFET

Problem-36:

Sketch the transfer characteristics for an n -channel depletion-type MOSFET with $I_{DSS} = 10 \text{ mA}$ and $V_P = -4 \text{ V}$.

$$V_{GS} = 0 \text{ V},$$

$$I_D = I_{DSS} = 10 \text{ mA}$$

$$V_{GS} = V_P = -4 \text{ V},$$

$$I_D = 0 \text{ mA}$$

$$V_{GS} = V_P/2 = -4/2 = -2 \text{ V},$$

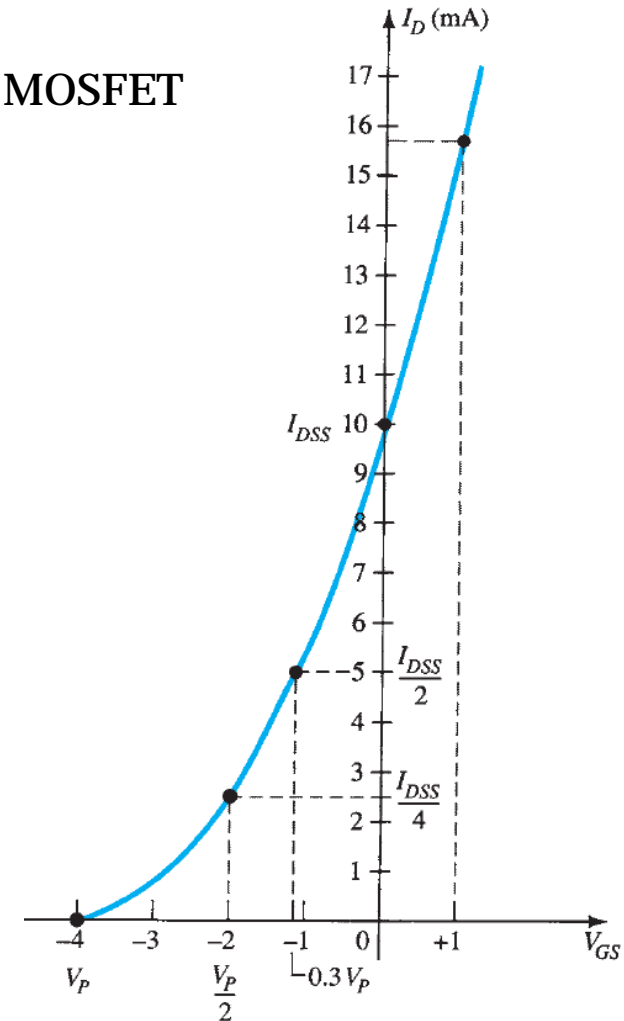
$$I_D = I_{DSS}/4 = 10/4 = 2.5 \text{ mA}$$

$$I_D = I_{DSS}/2,$$

$$V_{GS} = 0.3 V_P = 0.3(-4) = -1.2 \text{ V}$$

$$V_{GS} = +1 \text{ V} \rightarrow$$

$$I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_P}\right)^2 = 10 \times 10^{-3} \left(1 - \frac{+1}{-4}\right)^2 = 15.63 \text{ mA}$$

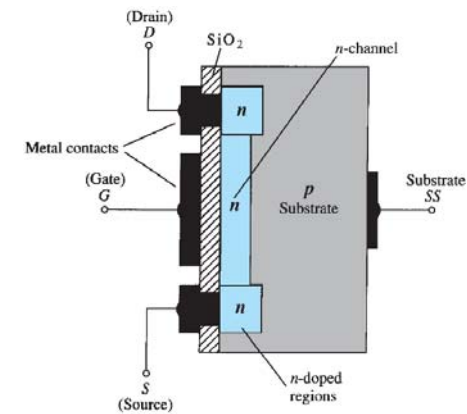
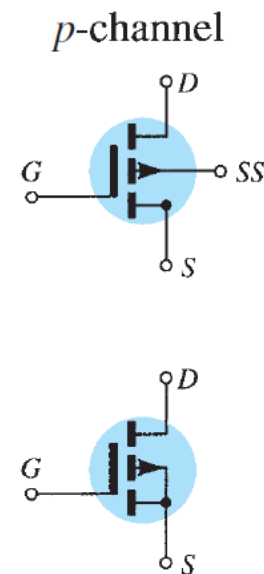
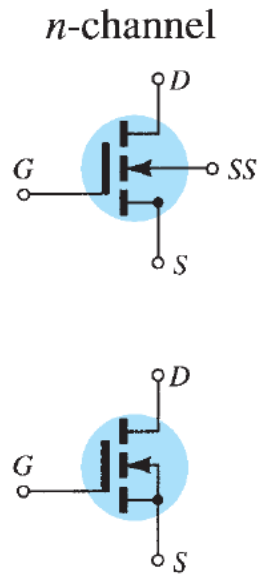
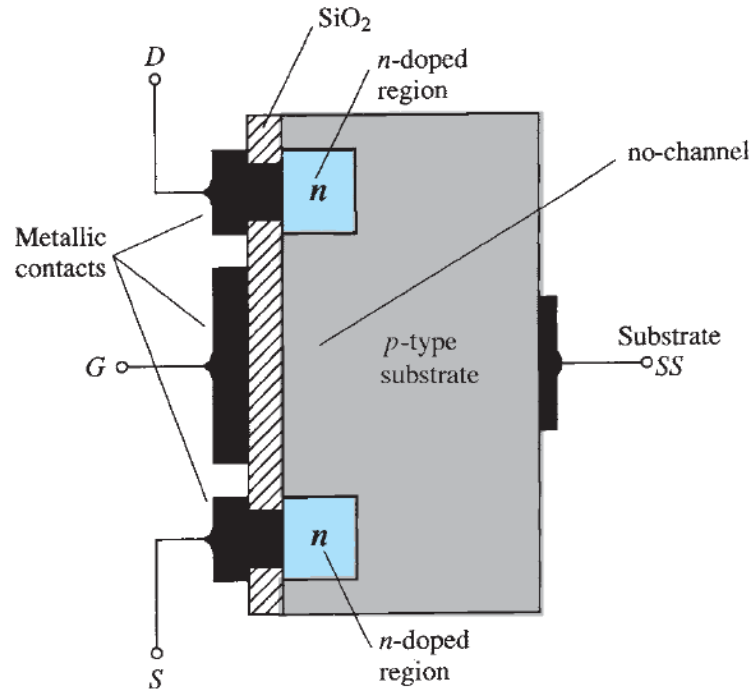


Enhancement-Type MOSFET

Construction of n -channel EMOSFET:

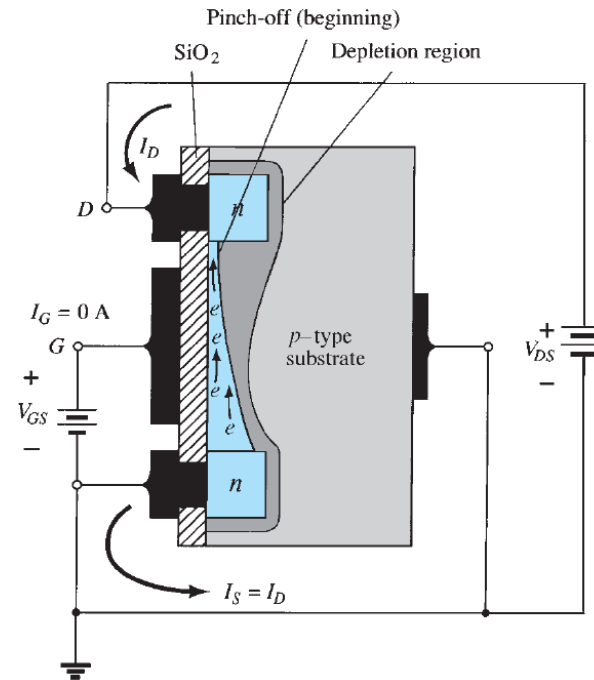
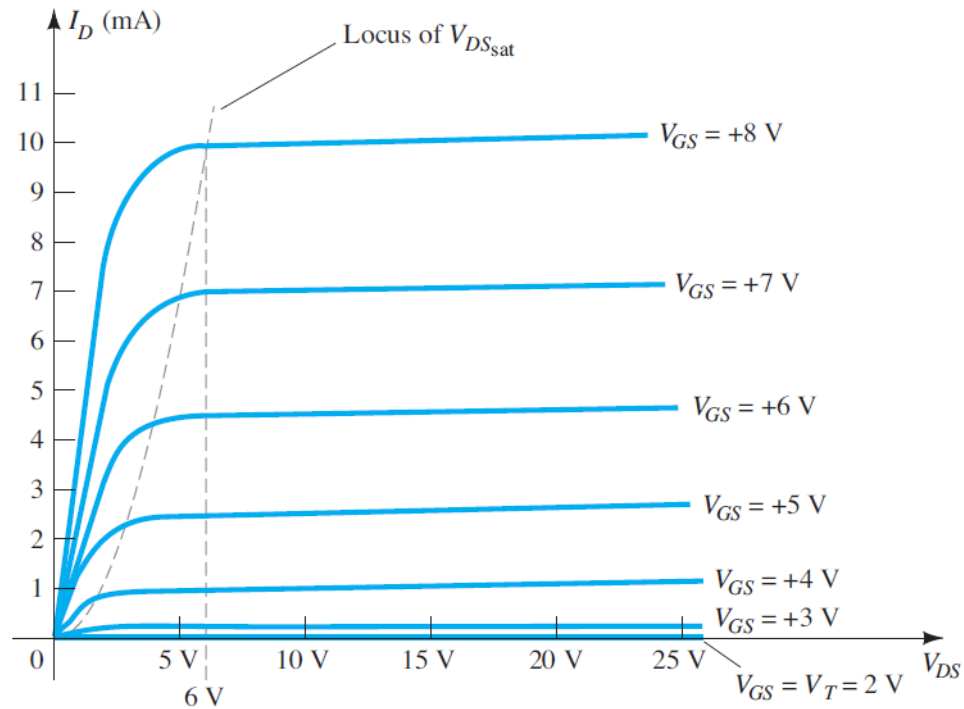
Channel is nonexistent with $V_{GS} = 0$ V.

Enhanced by application of +ve gate-to-source voltage.



Enhancement-Type MOSFET

Basic operation and characteristics:



Enhancement-Type MOSFET

Basic operation and characteristics:

Threshold voltage $V_T = V_{GS}$ that results in significant increase in I_D .

Pinch-off and saturation condition →

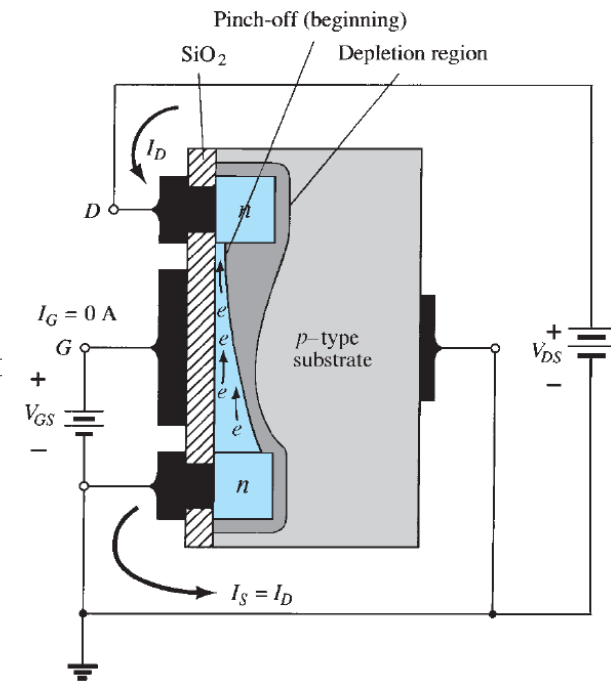
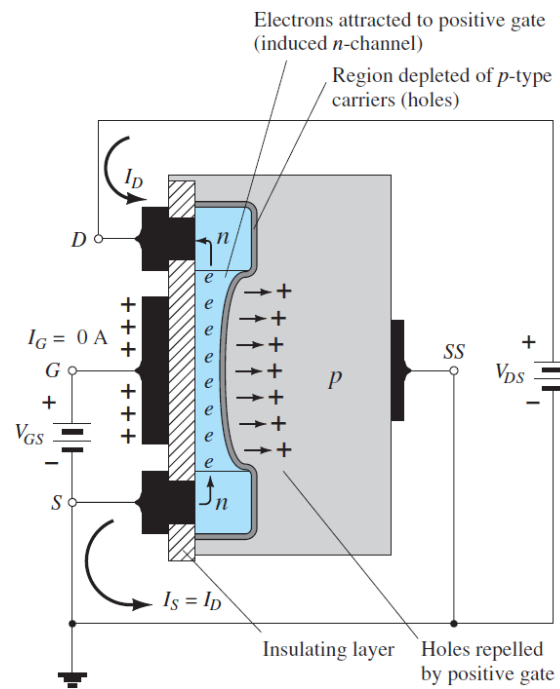
$$V_{DG} = V_{DS} - V_{GS}$$

V_{GS} = fixed at +ve voltage.

V_{DS} is increased →

gate becomes less +ve,
attractive forces for
free carriers reduces →
channel width reduces.

Further increase in V_{DS}
will not affect I_{DSS} .



Enhancement-Type MOSFET

Basic operation and characteristics:

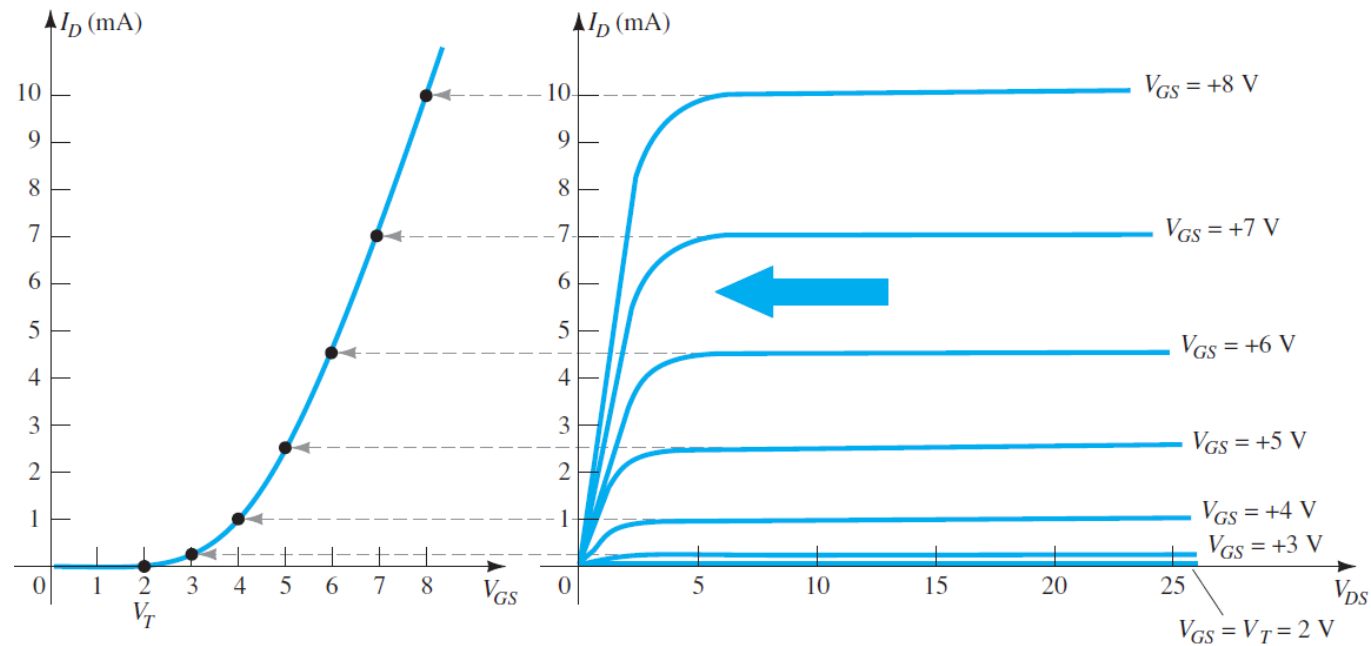
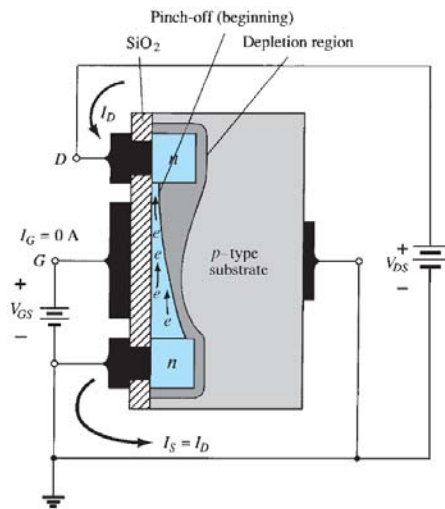
For $V_{GS} > V_T \rightarrow$

$$I_D = k(V_{GS} - V_T)^2$$

$k = \text{constant} = \text{function of construction of device.}$

$$k = \frac{I_{D(on)}}{(V_{GS(on)} - V_T)^2}$$

Drain and transfer characteristics \rightarrow



Enhancement-Type MOSFET

Problem-37:

Assuming $I_{D(on)} = 3 \text{ mA}$, $V_{GS(on)} = 7 \text{ V}$ and an average threshold voltage of $V_{GS(Th)} = 3 \text{ V}$, determine:

- The resulting value of k for the MOSFET.
- The transfer characteristics.

$$\text{a) } k = \frac{I_{D(on)}}{(V_{GS(on)} - V_T)^2} = \frac{3 \times 10^{-3}}{(7-3)^2} = 0.61 \times 10^{-3} \text{ A/V}^2$$

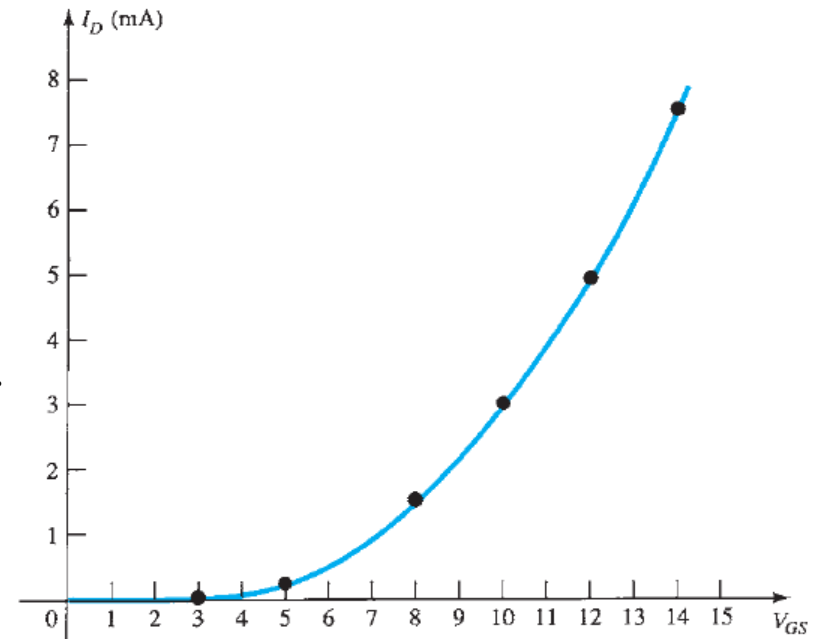
$$\text{b) } I_D = k(V_{GS} - V_T)^2 = 0.061 \times 10^{-3} (V_{GS} - 3\text{V})^2$$

For $V_{GS} = 5 \text{ V}$,

$$I_D = 0.061 \times 10^{-3} (5 - 3)^2 = 0.244 \text{ mA}$$

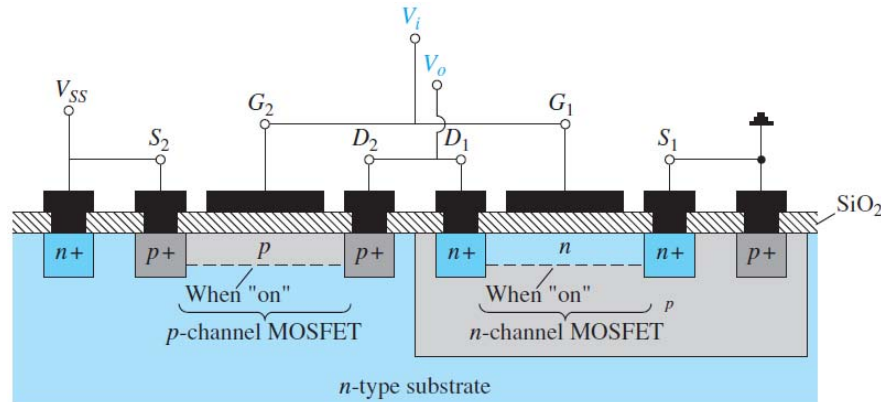
For $V_{GS} = 8, 10, 12$, and 14 V ,

$I_D = 1.525, 3, 4.94$, and 7.38 mA , respectively.



Complementary MOSFET (CMOS)

Construction:



CMOS as inverter:

